



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 10/678,513
Filing Date October 3, 2003
Inventor Werner Juengling
Assignee Micron Technology, Inc.
Group Art Unit 2812
Examiner B. Kebede
Attorney's Docket No. MI22-2391
Customer No. 021567

Title: Semiconductor Processing Methods of Forming a Contact Opening to a
Conductive Line and Methods of Forming Substrate Active Area
Source/Drain Regions


SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

The attached Form PTO-1449 is submitted in compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the references listed on the attached Form PTO-1449. Pursuant to Federal Register Vol. 69, No. 182, pg. 56542 (September 21, 2004), no copies of any cited U.S. patents or U.S. published applications are included herewith. Copies of all other cited art references, if any, are attached. No admission is made regarding whether the submitted references are prior art.

Citation of this reference is respectfully requested.

Respectfully submitted,

Dated: 4-10-06

By: 
D. Brent Kenady
Reg. No. 40,045

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. MI22-2391	SERIAL NO. 10/678,513
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Werner Juengling	
				FILING DATE October 3, 2003	GROUP 2823

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U.S. PATENT DOCUMENTS							
*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
AA	6,027,971	02/00	Cho, et al	438	257		
AB	5,488,001	01/96	Brotherton	999	021		
AC							
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